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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

JAN RAEBIGER  
HEIKO WAGNER  
UWE SCHULZE  
ROLF SELTMANN

Serial No.: 10/625,451

Filed: July 23, 2003

For: METHOD AND SYSTEM FOR  
IMPROVING EXPOSURE  
UNIFORMITY IN A STEP AND  
REPEAT PROCESS

Examiner: Alan A. Mathews

Group Art Unit: 2851

Att'y Docket: 2000.108200/DE0353

Customer No.: 23720

**RESPONSE TO FINAL OFFICE ACTION DATED JULY 14, 2005**

**Mail Stop AF**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

CERTIFICATE OF MAILING  
37 C.F.R 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:

September 7, 2005

Date

*Mary Paul*  
Signature

This paper is submitted in response to the Final Office Action dated July 14, 2005, for which the three-month date for response is October 14, 2005.

No fees are believed to be due in connection with the present paper. **However, should any fees be required under 37 C.F.R. §§ 1.16 to 1.21, the Director is authorized to deduct such fees from Advanced Micro Devices, Inc. Deposit Account No. 01-0365/DE0353.** In the event the monies in that account are insufficient, the Director is authorized to withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.108200.

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.